

Reg No.: _____

Name: _____

APJ ABDUL KALAM TECHNOLOGICAL UNIVERSITY

Third Semester B.Tech Degree (S,FE) Examination December 2020 (2015 Scheme)

Course Code: EC203**Course Name: SOLID STATE DEVICES (EC, AE)**

Max. Marks: 100

Duration: 3 Hours

PART A*Answer any two full questions, each carries 15 marks.*

Marks

- 1 a) Define Fermi-Dirac distribution function. Explain each term in it. With the help of plots, characterize temperature dependence of this function. (5)
- b) Starting from fundamentals, derive an expression to calculate the intrinsic carrier concentration of semiconductors. What are the factors on which intrinsic carrier concentration depends? (10)
- 2 a) With suitable assumptions, derive Einstein's relation for mobility of electrons in a semiconductor (7)
- b) A semiconductor is doped with $2 \times 10^{16} \text{ cm}^{-3}$ Boron atoms and $1 \times 10^{16} \text{ cm}^{-3}$ of Phosphorus atoms at 300 K. Calculate (8)
- The type of the sample
 - Electron and Hole concentrations
 - The fermi level position with respect to intrinsic energy level
 - Plot the energy band diagram indicating the band edges, E_f , E_i and the band gap energy.
($n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$ for Silicon at 300 K)
- 3 a) Derive one dimensional continuity equation for holes in a semiconductor. With suitable assumptions, obtain the diffusion equations for holes and electrons. (10)
- b) With suitable energy band diagram, explain the indirect recombination mechanism via traps. (5)

PART B*Answer any two full questions, each carries 15 marks.*

- 4 a) Plot the energy band diagram of a PN junction under (6)
- Equilibrium
 - Forward bias
 - Reverse bias

- b) With suitable assumptions, derive Ideal Diode equation. List the current depending factors (9)
- 5 a) Plot the Volt Ampere characteristics of a tunnel diode. Differentiate the energy band diagrams of forward biased, reverse biased and equilibrium conditions of the tunnel diode. (8)
- b) $1 \times 10^{16} \text{ cm}^{-3}$ of Donor atoms are implanted to an n type Silicon sample forming an abrupt junction of square cross section, with area $2 \times 10^{-3} \text{ cm}^2$. Assume that the acceptor concentration in the P type region is $4 \times 10^{18} \text{ cm}^{-3}$. Calculate (7)
- The built in potential
 - Width of the depletion layer
 - Extension of depletion layer to the n side and the p side of the junction
 - Junction capacitance
- (relative permittivity $\epsilon_r = 11.9$ and $n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$ for Silicon at 300 K)
- 6 a) With the help of energy band diagrams, distinguish behaviour of metal- n type Schottky contact and metal-n type Ohmic contact. (10)
- b) Distinguish between Zener and Avalanche breakdown mechanisms. (5)

PART C

Answer any two full questions, each carries 20 marks.

- 7 a) Draw the structure of a PNP transistor. Clearly Indicate the current components on the figure. (4)
- b) Define the basic performance parameters of BJTs? What is the effect of doping and dimensions of emitter, base and collector regions on these parameters? (9)
- c) The following parameters are given for a PNP transistor. $I_{EP} = 2 \text{ mA}$, $I_{En} = 0.01 \text{ mA}$, $I_{cP} = 1.98 \text{ mA}$ and $I_{cn} = 0.001 \text{ mA}$. Determine (7)
- The base transport factor
 - The emitter injection efficiency
 - α and β
 - I_E , I_C and I_B
- 8 a) Draw the structure and band diagram of a MOS capacitor with P type substrate, under equilibrium and under strong inversion. Give the condition for strong inversion with reference to band diagram. (6)
- b) Draw and explain the transfer characteristics of an enhancement type MOSFET. (4)
- c) An n channel MOS transistor is made on a P type silicon substrate with (10)

$N_A = 5 \times 10^{15} \text{ cm}^{-3}$. The oxide thickness is 100 \AA and the effective interface charge is $Q_i = 6.4 \times 10^{-9} \text{ C/cm}^2$. Work function difference is given as $\Phi_{ms} = -0.95 \text{ V}$. Calculate,

- i) Surface potential needed to make the surface strongly inverted.
- ii) Flat band voltage
- iii) Threshold voltage

(relative permittivity $\epsilon_r = 11.9$ and $n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$ for Silicon at 300 K)

- 9 a) Derive the expression for the drain current of a MOSFET. How will the equation (10) modifies in
- i) Linear region
 - ii) Saturation region of operations.
- b) What is base width modulation? How does it affect the BJT characteristics in CE (6) and CB configurations?
- c) Plot the distribution of minority carriers in the bulk of a PNP transistor in active (4) mode of operation.
